ARIM Users’ Report

*※required items*

※Number of project ：

※Type of user support (main) ：　Technical Consultation, Equipment Operation by Users,

Technical Assistance, Operation on behalf of users,

Research Collaboration, Data Utilization

Type of user support (sub) ：　Choose one from 6 domains shown above.

※Program Title　　 ：

※User name ：

※Affiliation ：

Information of user

　　 ORCID ：　0000-0001-1234-0001

※Age group ：　Under 20's, 30's, 40's, Over 50's

※Affiliation class ：　University or College, Public research institute,

　　Large Enterprise, Small and medium enterprise, Others

（These information (ORCID, Age Grope, Category of Affiliation et al.) will not be shown in a users' report in public.）

※Use Competitive Funds from National Budget for payment of usage fees.：　No　/　Yes

In a Case of Yes → The Kind of a Fund：JSPS-Kakenhi, JSPS-Others, JST-CREST・ERATO

JST-SakigakeFOREST, JST-A-step, JST-Others ,MEXT-Others, MEDE NEDO, AMED, Cabinet Office,

In a Case of Others→Name of competitive Fund　：

Research Category of Competitive Fund：

※Postponement of publication ：　Not desired Desired (Extention period:　yy/mm/dd） up to 2 years

Reason: In a Case of Desired,Please check the box (Multiple check allowed)

□corporate strategy

□patent application

□submission of paper

□preparation for conference presentation

□other

Names of other users ：　物質太郎, 材料花子, John Smith

Names of ARIM staffs ：　物質太郎, 材料花子, John Smith

※Cross cutting technical area (main)：　Measurement and analysis

　　　Fabrication and device processing

　　　Materials and synthesis processing

　　　Computational Science and simulation

Cross cutting technical area (sub)：　Choose one from 4 domains shown above.

※Key technology domain (main)：

Materials allowing high-level device functions to be performed

Materials using quantum and electronic control to perform innovative functions

Materials enabling innovative energy conversion

Advanced materials recycling technologies

Next-generation biomaterials

Next-generation nanoscale materials

Multi-material technologies and next-generation high-molecular materials

Key technology domain (sub)：　Choose one from 7 domains shown above.

Facility ID's you used ：　Please fill in the main facility ID or name you used.

Keywords　　　　　　　：　Please fill in at least 3 words.

※Summary：

　(In the case of technical consultation, it is acceptable to fill only the summary.)

※Experimental：

　(Describe the experimental method etc.)

※Results and Discussion：

　(Enter at least 200 characters to enhance the report.)

　(Include figures if necessary.)

Others：

　(Include references, terminology, acknowledgments, etc. as necessary.)

●Publications / Proceedings (Enter DOI)

For papers that have not yet been assigned a DOI, please add them after the DOI has been assigned.

For papers without DOI, please fill in the oral presentation column.

●Oral presentations etc.

●Patents Enter both at the time of publication and at the time of registration.

※Number of Patent Applications：0

Application Numbers：

These numbers will not seen in a users’ report.

※Number of Registered Patents：0

Patent Registration Numbers：

These numbers will not seen in a users' report.

●If you have any additional information to include after submitting your report, please email us.

Central Hub of Advanced Research Infrastructure for Materials and Nanotechnology, Promotion Office of a Key Technology Domain

E-mail：arim-hub[at]nims.go.jp (Please change "at" to "@")